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Highly sensitive non-enzymatic hydrogen peroxide monitoring platform based on nanoporous gold via a modified solid-phase reaction method†

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In this work, nanoporous gold (NPG) fabricated using a modified solid-phase reaction method was developed as an electrocatalyst for the nonenzymatic detection of hydrogen peroxide (H₂O₂). The NPG morphology and structure were characterized by scanning electron microscopy and high-resolution transmission electron microscopy. The fabricated NPG exhibited a nanoporous framework with numerous structural defects. The NPG-based amperometric H₂O₂ sensor had a good selectivity, reproducibility, and low detection limit (0.3 μM) under near physiological conditions (pH = 7.4). The sensitivities of this sensor over concentration ranges of 0.002–5 mM and 5–37.5 mM were 159 and 64 μA mM⁻¹ cm⁻², respectively. These results indicate that the developed NPG is a promising material for the electrochemical sensing of H₂O₂.

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1. Introduction

Hydrogen peroxide (H₂O₂) is widely used in several fields such as food, pharmaceutical, and biological applications.^{1–3} This excessive use of H₂O₂ can have adverse effects on human health and safety. Thus, analytical determination of H₂O₂ is essential. Currently, there are several available H₂O₂-detection techniques such as fluorometry,^{4–6} chromatography,^{7,8} spectrophotometry,^{9,10} chemiluminescence,¹¹ electrochemistry,¹² titrimetry,¹³ and electrochemical methods.¹⁴ The electrochemical methods are among the most effective H₂O₂-detection techniques due to their high sensitivity, fast response, and operational simplicity. These methods detect H₂O₂ through concentration-dependent electrical signals generated when the H₂O₂-containing samples are exposed to an electrocatalyst. Two types of electrochemical sensors (enzyme-based and non-enzymatic sensors) have been developed for H₂O₂ detection. Enzyme-based sensors exhibit serious disadvantages^{15–19} such as poor reproducibility, sensitivity to pH, low stability, and time-consuming immobilization procedures. Thus, the development of effective and stable non-enzymatic electrode materials is essential.

Various electrode materials have been reported as suitable scaffolds for H₂O₂ detection.^{20–29} Among them, nanoporous gold (NPG), which has a three-dimensional interconnected porous nanostructure, has attracted significant interest due to its high specific surface area, high electrical conductivity, excellent catalytic activity and good biocompatibility. NPG was recently prepared using a solid-phase reaction method (SPRM) based on a metal-induced crystallization (MIC) process, which exhibited enhanced electro-catalytic properties.^{30–34} In this study, NPG was designed and manufactured using a modified SPRM method. A triple-layer precursor, *i.e.*, a-Ge (amorphous Ge, top)/Au (middle)/a-Ge (bottom) film precursor, was used to accelerate the MIC process. Using this triple-layer structure, NPGs with nanopores smaller than those prepared using the previously reported double-layer Au (bottom)/a-Ge (top) precursors were obtained. The morphological results indicated that NPGs with smaller grains and nanopores could be obtained using this modified SPRM method. The electrochemical performance of the prepared NPGs during the catalytic reduction of H₂O₂ was systematically investigated. The results indicated that the obtained NPGs are promising materials for non-enzymatic electrochemical H₂O₂ sensors.

2. Experimental

2.1. Preparation of the catalyst

The bilayer precursor structure obtained in a previous study consisted of amorphous Ge (a-Ge, top)/Au (bottom).¹⁹ Here, a thin a-Ge film was inserted between the previous Au (bottom) layer and the substrate, resulting in a triple-layer film precursor (a-Ge (top)/Au (middle)/a-Ge (bottom)). This precursor thin film

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was deposited onto Si(100) wafers (covered with 50 nm-thick amorphous SiO₂) using magnetron sputtering at 120 °C in a high-vacuum system (base pressure $\leq 1.0 \times 10^{-5}$ Pa). Substrates were thoroughly washed before deposition using acetone, ethanol, and ultrapure water. Before sputtering, they were cleaned under Ar⁺ atmosphere in a vacuum chamber for 5 min. A pure gold target and a pure germanium target were used for direct-current sputtering Au sublayer and radio frequency sputtering Ge sublayer, respectively. A 4 nm-thick a-Ge sublayer was first obtained on the substrate at a rate of 1 nm min⁻¹. Next, while still under vacuum, a 20 nm Au sublayer was deposited on top of the bottom Ge layer. The direct-current sputtering power was 16 W and the deposition rate was 3.3 nm min⁻¹. A 40 nm a-Ge layer was finally deposited on top of the Au film. The deposition rate was 11.6 nm min⁻¹. The substrates were maintained at 120 °C during the entire deposition process to encourage the MIC process of the deposited Au and Ge films, in which the mutual transport of Au and Ge atoms led to the formation of network-like nanostructures. Samples were continuously rotated at 20 rpm during the sputtering deposition process to ensure sample uniformity. The as-sputtered samples were then immersed in a hydrogen peroxide solution (30 vol%) for 5 minutes at 25 °C, resulting in a selective removal of Ge from the precursor. Finally, the samples were thoroughly rinsed and dried using ultrapure water and a stream of nitrogen, respectively.

2.2. Characterization of NPGs

Scanning electron microscopy (SEM) with energy-dispersive spectroscopy (EDS) measurements were carried out using a Hitachi S-4800 microscope operated at 15 kV. More detailed high resolution transmission electron (HRTEM) and selected-area electron diffraction (SAED) pattern were characterized by a JEM-2100F microscope (200 kV). The average grain size was determined based on measurements of 300 individual grains using SEM micrographs.

2.3. Electrochemical detection of H₂O₂

Electrochemical measurements were performed with an electrochemical workstation (CHI 660E) at 25 °C. A three-electrode system composed of a 3 mm-diameter NPG-modified glassy carbon electrode (NPG/GCE), saturated calomel electrode (SCE), and platinum wire as the working, reference, and counter electrodes, respectively, was used for the measurements. The working electrode was prepared by the procedure described in Section 2.1, using glassy carbon electrodes as the substrates. For comparison, a polycrystalline gold-modified electrode (Poly-Au/GCE) was prepared using the same magnetron sputtering parameters. Before the fabrication, the bare glassy carbon electrodes were polished to a mirror-like state using Al₂O₃ suspensions (0.5 and 0.05 μm) and rinsed with pure ethanol and distilled water. They were then dried using nitrogen steam. All experiments were performed at room temperature. Before each electrochemical test, all electrolytes were deoxygenated using nitrogen bubbling (purity ≥ 99.999 vol%) for at least 30 min.

The electrode surface was initially cleaned using ultrapure water and subsequently subjected to 20 cycles of cyclic voltammetry (CV) between -0.8 and 0.8 V in 0.1 M KOH solution. The scan rate was 50 mV s⁻¹. During this process, the NPG/GCE was activated due to OH⁻ penetration in NPG. The CV measurements were conducted in N₂-saturated phosphate-buffered solutions (PBS, 0.1 M, pH = 7.4) without and with H₂O₂ (10 mM) at a scan rate of 50 mV s⁻¹. The effect of the scan rate on the reduction-peak currents was also examined in detail. The amperometric (*I*-*t*) measurement at -0.8 V was used to assess the sensitivity of the electrode material toward H₂O₂ in a continuously stirred PBS solution (pH = 7.4), while recording the change in the current with the increase in the H₂O₂ concentration. The electrode selectivity was assessed by conducting the detection in a solution containing interferents (*i.e.*, ascorbic acid (AA), uric acid (UA), and glucose (GLU)).

3. Results and discussion

Fig. 1a-d shows SEM and TEM micrographs of NPG prepared using the triple-layer a-Ge (thick, top)/Au (middle)/a-Ge (thin, bottom) film precursor. The NPG thin film exhibited a typical bicontinuous porous structure. The sizes of the NPG grains and nanopores (approximately 14 nm, see the inset in Fig. 1a) were smaller than those of NPG (approximately 26 nm) obtained using a bilayer precursor.³⁵ This can be attributed to the thermodynamic instability of the Au/a-Ge interface of the triple-layer precursor structure.^{36,37} This instability was caused by placing a gold layer between two amorphous germanium layers, and it increased the driving force of the MIC reaction, accelerating its rate. In addition, the composition of the triple-layer precursor film, as analysed by EDS, is 62 at% Ge and 38 at% Au.

At the beginning of the metal-induced crystallization process, the amorphous germanium atoms above and below the gold sublayer rapidly diffused along the Au grain boundaries in the gold sublayer. Next, they began to nucleate and produce high density Ge nanocrystalline grains at the gold grain boundaries, resulting in trapping the nanoscale crystalline Ge (c-Ge) in the original Au sublayer. The continuation of the MIC process generated a large stress gradient inside the multilayer film.³¹ The atoms in the Au sublayer then further diffused to occupy the a-Ge position, promoting the formation of Au nanostructures in the original a-Ge position. As described in Section 2.1, the bottom Ge film must be sufficiently thin (4 nm) to ensure the connection between the gold sublayer and substrate when the MIC process is completed. Subsequently, the germanium was selectively etched from the precursor. As a result, the positions that were occupied by the crystalline germanium in the Au sublayer were exposed, revealing large number of nanopores. Thus, nanoporous gold with the desired morphology was obtained. Due to the good selective etching effect of hydrogen peroxide, the NPG film prepared by the solid-phase reaction method has extremely high purity without residual germanium.^{33,34} The inset in Fig. 1c shows the SAED pattern of NPG thin film, which indicates the nanocrystalline nature of the obtained NPG thin film.³⁸



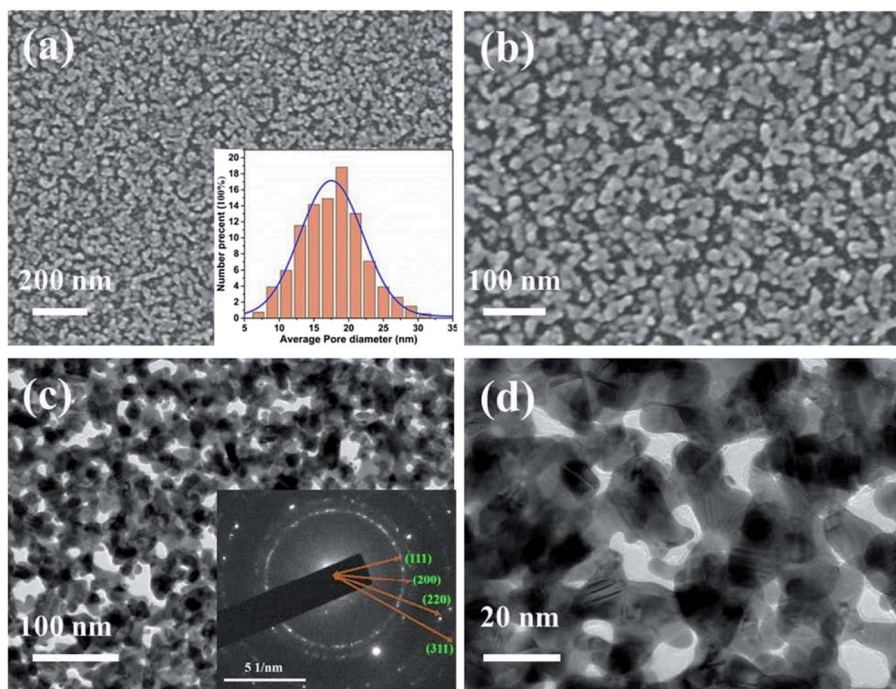


Fig. 1 Microstructure of the NPG thin film prepared by the modified solid-phase reaction method: (a, b) SEM and (c, d) TEM images. The inset in (a) and (c) are the average nanopore size and the corresponding SAED pattern of the NPG thin film, respectively.

Fig. 2a–c show the HRTEM results, revealing that the NPG material contained various typical structural defects such as grain boundaries (Fig. 2a), twins (Fig. 2b) and stacking faults (Fig. 2c). These defects, which are associated with the presence of a high concentration of low-coordination atoms, can effectively work as catalytic active sites in several catalytic reactions.^{39–43} In addition, the open nanoporous structure with small grains and nanopores creates a large electrochemically

active surface area (about 0.33 cm^2). Therefore, the as-prepared NPG thin film was expected to show good electrochemical performance during H_2O_2 detection.

Before the electrocatalytic measurements, the electrochemical impedance spectroscopy (EIS) was first tested using the method listed in the ESI methods and the result is shown in Fig. S1.† It is found that the diameter of semicircular part of the curve corresponding to the electron transfer resistance (R_{ct}) of

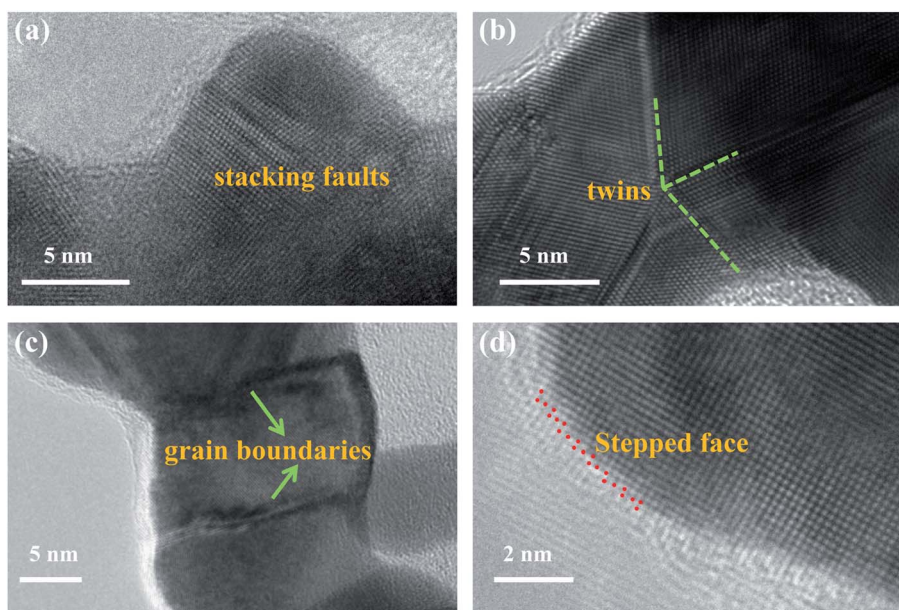
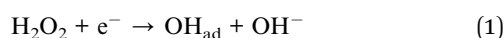


Fig. 2 Representative HRTEM images of the NPG thin film prepared by the modified solid-phase reaction method, showing surface defects: (a) stacking faults, (b) twins, (c) grain boundaries and (d) stepped face.



the redox reaction is lower (about 65 Ω), suggesting its good conductivity.

After EIS measurements, the electrocatalytic performances were measured using CV. Fig. 3a and b show a comparison between the CV curves of Poly-Au/GCE and NPG/GCE, respectively, in N_2 -saturated PBS solution (0.1 M, pH = 7.4) without and with H_2O_2 (10 mM). The Poly-Au/GCE showed low electrocatalytic activity, generating a weak reduction current and onset potential (approximately: -0.2 V) after the addition of H_2O_2 (10 mM). In contrast, NPG/GCE generated a strong current response to H_2O_2 at the same potential and a higher positive onset potential at approximately 0 V. The reduction peak of H_2O_2 occurred at -0.83 V with a peak current four times larger than that obtained from Poly-Au/GCE. The reduction of H_2O_2 on the surface of NPG/GCE follows the electroreduction mechanism described in eqn (1)–(3):^{44,45}



The results obtained in this study support this reaction mechanism because the onset potential of H_2O_2 reduction (Fig. 3) was almost equal to the adsorption potential of OH^- .⁴⁶ The significant electroreduction of H_2O_2 by NPG/GCE can be ascribed to the fast interfacial electron transfer on the nanoporous gold nanostructures, which reduces the overpotential

and increases the response current.⁴⁷ Fig. 3c illustrates the CV curves obtained using an NPG/GCE electrode with H_2O_2 (10 mM) at various scan rates (10–80 $mV s^{-1}$). Fig. 3d indicates a linear relationship ($R^2 = 0.996$) between the cathodic peak current and the square root of the scan rate, signifying that a classical diffusion-controlled electrochemical process occurred on the NPG/GCE electrode surface.

The pH effect on the NPG/GCE performance during the electroreduction of H_2O_2 was studied by conducting CVs of NPG/GCE under various pH conditions (Fig. 4). Due to the instability of H_2O_2 under alkaline conditions, H_2O_2 reduction was not tested at higher pH values. The reduction peak current increased with pH (from 6.2 to 7.8), and the most positive peak

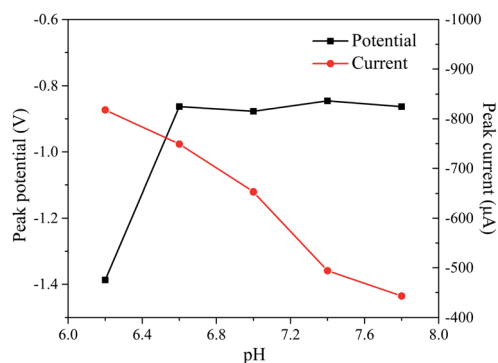


Fig. 4 Peak currents and peak potentials in H_2O_2 (10 mM) at different pH values.

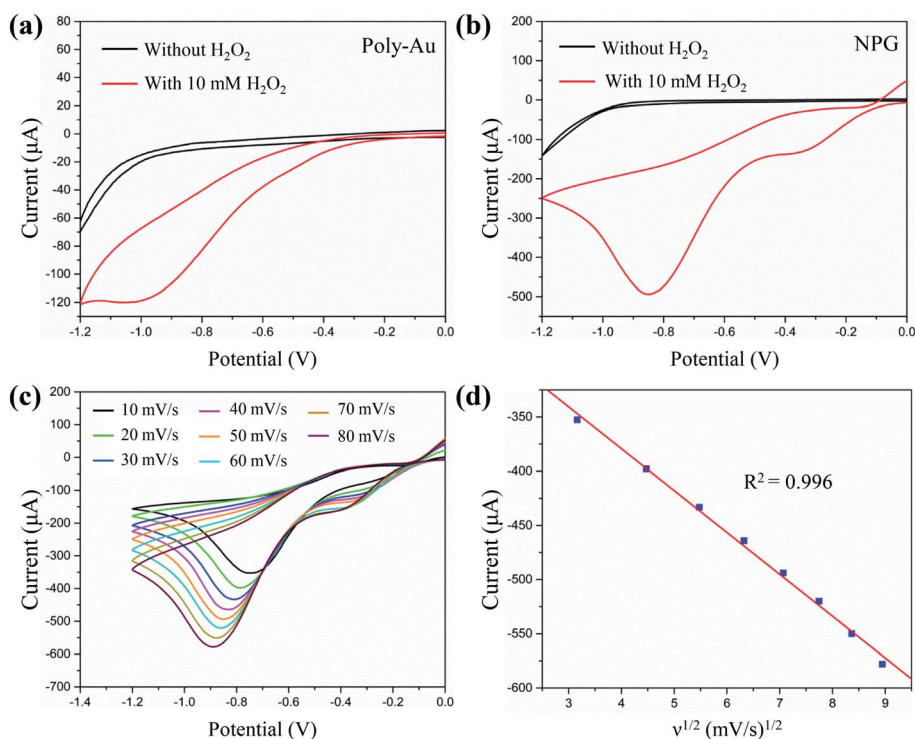


Fig. 3 Cyclic voltammograms of (a) Poly-Au/GCE and (b) NPG/GCE in PBS solutions (0.1 M, pH = 7.4) without and with H_2O_2 (10 mM), the scan rate was 50 $mV s^{-1}$, (c) cyclic voltammograms of NPG/GCE in a PBS solution (0.1 M, pH = 7.4) with H_2O_2 (10 mM) at varying scan rates, and (d) cathodic peak current vs. scan rate.



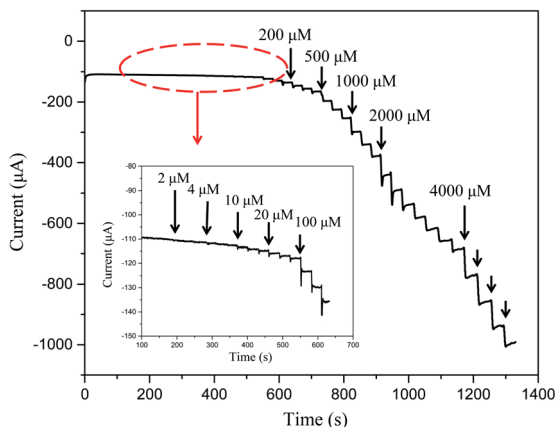


Fig. 5 Amperometric recording obtained at the NPG/GCE electrode for different H₂O₂ concentrations (applied potential: -0.8 V). The inset shows a magnified amperometric response in a lower H₂O₂ concentration range.

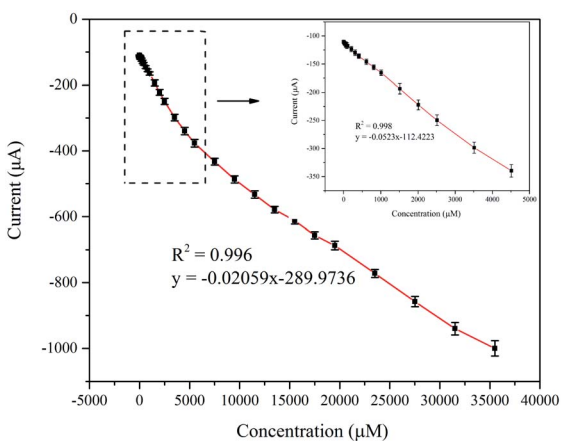


Fig. 6 Calibration curves of the NPG/GCE electrode used in H₂O₂ detection.

potential occurred at -0.83 V at pH = 7.4. Therefore, a pH of 7.4 was selected to detect H₂O₂ in the following experiment.

The practical use of NPG/GCE as a sensing electrode was assessed by examining its electrochemical response to H₂O₂.

This was conducted by monitoring the change in the current with increasing hydrogen peroxide concentration in a 0.1 M PBS solution at a potential of -0.8 V. Fig. 5 shows the amperometric response of NPG/GCE, which indicates that the response current stabilizes within 2 s after each H₂O₂ addition, suggesting that the electrochemical sensor exhibited rapid diffusion and electron-exchange performance. In addition, the amperometric response exhibited a step-like increase with the H₂O₂ concentration, indicating high sensitivity. Therefore, the correlation between the concentration of the added H₂O₂ and the corresponding current response can be used as a calibration curve for H₂O₂ detection (Fig. 6). A well-defined linear current response was observed with the increase in the H₂O₂ concentration in two distinct regions: 2 μM to 5 mM and 5–37.5 mM. The calibration linear regression equations of these two regions are described with the eqn (4) and (5):

$$I (\mu\text{A}) = -0.0523 [\text{H}_2\text{O}_2] (\mu\text{M}) - 112.422 \quad (2 \mu\text{M to } 5 \text{ mM}) \quad (4)$$

$$I (\mu\text{A}) = -0.0206 [\text{H}_2\text{O}_2] (\mu\text{M}) - 286.974 \quad (5 \text{ mM to } 37.5 \text{ mM}) \quad (5)$$

The sensor sensitivity values for the first and second linear regions were estimated to be approximately 159 and 64 μA mM⁻¹ cm⁻², respectively. The limit of detection (LOD) were found to be 0.3 μM with a signal to noise ratio of 3 (S/N = 3). A comparison between the sensitivity parameters of NPG/GCE and other Au-based non-enzymatic electrochemical sensor materials is summarized in Table 1. The NPG electrode developed in this work exhibited a much wider detection range and a higher sensitivity for the detection of concentrated H₂O₂ than those of the previously reported electrodes.^{48–53} This excellent electrocatalytic activity of NPG/GCE can be ascribed to the large active surface area and plenty of active sites generated due to the solid phase reaction and plent of active sites generated due to the solid phase reaction method used here (refer to Fig. 2 and the discussion in Sec. 2.1).

The repeatability of the electrochemical sensor was examined by subjecting the NPG/GCE electrode to 5 repeated CV experiments in a PBS (0.1 M, pH = 7.4) solution with H₂O₂ (10 mM). The relative standard deviation (RSD) of the reduction peak current over five independent tests was only 1% (Fig. 7a).

Table 1 Comparison between non-enzymatic Au-based H₂O₂ sensors^a

Electrode materials	Sensitivity (μA mM ⁻¹ cm ⁻²)	LOD (μM)	Linear range (μM)	Working potential	Ref.
GQD/Au electrode ^b	51	0.7	2–8000	-0.4	48
Au-PDA-GQD ^c	48	0.006	0.1–40	-0.1	49
	8		40–20 000		
Au NG@NC ^d	101	29	50–30 000	-0.5	50
Au nanowires	185	111	500–50 000	-0.7	51
Au NP-silica sol-gel	30	0.003	2.5–45	-0.5	52
Nanoporous gold	21	3.26	5–28 000	-0.4	53
NPG	159	0.3	2–5000	-0.8	This work
	64		5000–35 000		

^a LOD = 3(RSD/slope). ^b Graphene quantum dots/gold electrode. ^c Au-polydopamine-graphene quantum dots. ^d Gold nanograss-nanocube assemblies.



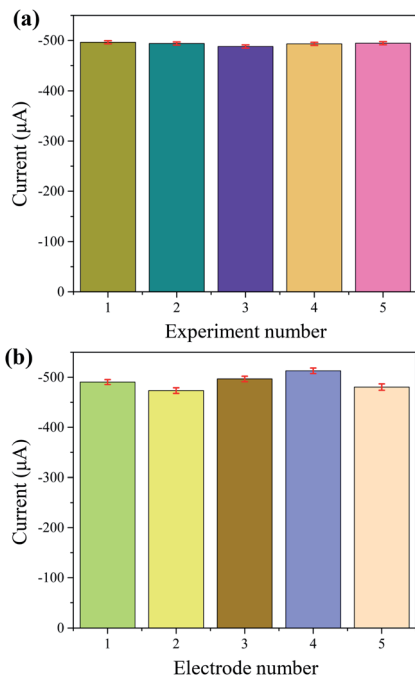


Fig. 7 (a) The repeatability of five experiments using the same NPG/GCE electrode, (b) reproducibility investigation using five NPG/GCE electrodes under the same preparation parameters. In each case, H_2O_2 (10 mM) was added.

In addition, five NPG/GCE were fabricated for H_2O_2 detection under the same conditions. Fig. 7b shows their reduction-peak-current values. The RSD among these values was calculated to be 3%, indicating a good reproducibility of the sensor.

Moreover, the presence of some possible co-existing species in a practical environment may cause interference to current response of the electrodes. Therefore, selectivity is also a key indicator for the actual application of the sensors. Herein, the amperometric response of the NPG/GCE was monitored during the successive injection of interfering substances in the PBS solution (0.1 M). Fig. 8 indicates that there was only a weak response to the addition of multiple interferents (AA, 4 mM; UA, 4 mM; and GLU, 4 mM). However, after the addition of H_2O_2 (0.2 mM), a very clear current response was obtained. Thus, the effect of interfering species on the sensor response during H_2O_2 detection was negligible. Therefore, the developed NPG/GCE sensor exhibited excellent selectivity and anti-interference performance during H_2O_2 detection.

It is well-known that H_2O_2 is often used as a stabilizer or a preservative in milk, but excess addition of H_2O_2 is very harmful to our health. As a result, it is extraordinarily important to monitor the concentration of H_2O_2 . For verifying the feasibility of the prepared electrode, the sensor performance of NPG electrode in real sample (the milk sample is selected here) was tested according to the method in the ESI method.[†] The recoveries of H_2O_2 in milk sample are calculated using the corresponding linear regression equation in the insert of Fig. 6. The results are summarized in Table S1 (ESI),[†] which shows that the recoveries of milk sample with 1 mM, 2 mM and 5 mM H_2O_2 is 101.0%, 96.5% and 98.4%, respectively. The results

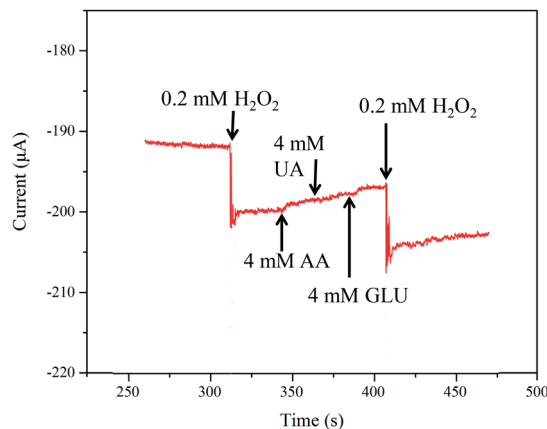


Fig. 8 Effects of AA (4 mM), UA (4 mM), GLU (4 mM) on the amperometric responses of the NPG/GCE electrode in a N_2 -saturated PBS solution (0.1 M, pH = 7.4).

further indicate the prepared NPG electrode has good potential to monitor H_2O_2 .

4. Conclusions

A modified solid-phase reaction method was developed based on the MIC process to form NPG thin films using a Ge (thin, bottom)/Au/Ge (thick, top) triple-layer precursor. The NPG thin film prepared by this method exhibited nanoscale grains (approximately 14 nm) smaller than those of the double-layer Au (bottom)/Ge (top) precursor. The as-developed NPG thin film exhibited outstanding electrochemical properties such as high sensitivity, wide linear range, and good selectivity for the electrochemical detection of H_2O_2 under near-physiological conditions. The excellent electrochemical performance of the sensor can be ascribed to its large active surface area and unique structure, which includes numerous defects generated during the preparation process. These results confirm that the developed NPG thin film can be used as a suitable platform for non-enzymatic electrochemical detection of H_2O_2 .

Conflicts of interest

There are no conflicts to declare.

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